

FORM PTO 1449	Atty. Docket No.: 169.12-0556	Application No.: 10/674,173 19/673,740
LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT	First Named Inventor: Kalman Pelhos	
	Filing Date: September 29, 2003	Group Art: 2652 1753

U.S. PATENT DOCUMENTS

Examiner Initials	Document No.	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Documents
AA			
AB			

FOREIGN PATENT DOCUMENTS

		Foreign Patent Document	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Documents	Translation Yes No
SHV	AC	WO8007250	06-14-1994	Hitachi Ltd G11B 5/06	No
SHV	AD	2002042326	07-19-00	KYOCERA CORP G11B 5/08	Yes

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

SHV	AE	Kiwamu Tanahashi, Yuzuru Hosoe, Masaaki Futamoto; <i>Magnetic Anisotropy and Microstructure of Obliquely Evaporated Co/Cr Thin Films</i> ; July 24, 1995; pgs. 265 - 272.
SHV	AF	Y.F. Zheng and J.P. Wang; <i>Control of the Tilted Orientation of CoCrPt/Ti thin film media by collimated sputtering</i> ; May 15, 2002; V931 pgs. 0007 - 0009.
SHV	AG	M.J. Hadley, R. Atkinson, R.J. Pollard; <i>Magnetic Properties of Co Films Deposited Onto Obliquely Sputtered Ta Underlayers</i> ; January 31, 2002.
SHV	AH	Dieter Weller and Andreas Moser; <i>Thermal Effect Limits in Ultrahigh-Density Magnetic Recording</i> ; November 1999; volume 35, pgs. 4423 - 4439.
SHV	AI	R.D. McMichael, C.G. Lee, J.E. Bonevich, P.J. Chen, W. Miller, and W.F. Egelhoff, Jr; <i>Strong Anisotropy in Thin Magnetic Films Deposited on Obliquely Sputtered Ta Underlayers</i> ; volume 88, No. 9, pgs. 5296 - 5299.0
SHV	AJ	A. Hagemeyer, H.J. Richter, H. Hibst, V. Maier and L. Marosi; <i>Crystallographic Texture and Morphology of Obliquely Deposited Co-Cr Magnetic Thin Films on Flexible Polymeric Substrates</i> ; August, 10, 1993; pgs. 199 - 202.
SHV	AK	T. Hikosaka, Y. Tamaka, T. Sonoda, and R. Nishikawa; <i>Cr Underlayer's Effect on the Magnetic and Crystalline Properties of Co Alloy Film</i> ; June 1988; volume 3, No. 6, pgs. 423 - 424.
SHV	AL	J.C. Lodder; <i>Magnetic Thin Films for High-Density Recording</i> ; 1996; pgs 474 -483

EXAMINER: 

DATE CONSIDERED: June 20, 2005

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

FORM PTO-1449	Atty. Docket No.: 169.12-0573	Application No.: 10/673,746
	First Named Inventor: Kalman Pelhos	
	Filing Date: Herewith <u>Sept 29, 2003</u>	Group Art: <u>1753</u>

LIST OF PATENTS AND PUBLICATIONS FOR
APPLICANT'S INFORMATION
DISCLOSURE STATEMENT

U.S. PATENT DOCUMENTS

Examiner Initial	Document No.	Date	Name	Class	Sub Class	Filing Date If Appropriate
SHV	AA	5,198,090	03/30/1993	Galicki et al.	204	298.11
SHV	AB	5,804,046	09/08/1998	Sawada et al.	204	298.11
	AC					
	AD					
	AE					
	AF					
	AG					
	AH					
	AI					
	AJ					
	AK					


FOREIGN PATENT DOCUMENTS

		Document No.	Date	Country	Class	Sub Class	Translation Yes No
SHV	AL	07-141610	02/06/1995	Japan	G11B	5/187	No
SHV	AM	09-212855	15/08/1997	Japan	G11B	5/182	No
SHV	AN	58-128023	30/07/1983	Japan	G11B	5/66	No
SHV	AO	2002-020864	23/01/2002	Japan	G23C	14/34	

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

SHV	AP	Y. F. Zheng and J. P. Wang and V. Ng, Control of the tilted orientation of CoCrPt/Ti thin film media by collimated sputtering; May 15, 2002; Journal of Applied Physics; Volume 91, Number 10				
EXAMINER: <u>[Signature]</u>			DATE CONSIDERED: <u>June 29, 2005</u>			

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FORM PTO-1449		Atty. Docket No.: 169.12-0573	Application No.: 10/673,746
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		Filing Date: September 29, 2003	Group Art: 1753

U.S. PATENT DOCUMENTS

Examiner Initials	Document No.	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Documents
SHV	AA	US2003/0019745	01-30-2003 Wang et al. 204/ 298.11
	AB		

FOREIGN PATENT DOCUMENTS

		Foreign Patent Document	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Documents	Translation Yes No
SHV	AC	EP05280473	02-05-1995	Sony Corp. 623C 14/44	YES
SHV	AD	EP08298096	10-21-1996	Ricoh Co Ltd. 623C 14/34	YES
SHV	AE	EP06131571	12-01-1996	Hitachi LTD. 611B 5/66	YES

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

SHV	AF	PCT/US03/30489, Notification of Transmittal of the International Search Report or the Declaration, August 2004, pages 1-3.
SHV	AG	PCT/US03/30489, International Search Report, August 2004, pages 1-4.
SHV	AH	McMichael et al., Strong Anisotropy in Thin Magnetic Films Deposited on Obliquely Sputtered Ta Underlayers, November 2000, pages 5296-5299.

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